

DOCKET NO.: 240882US0

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF :

TOMOHISA KONNO ET AL :

SERIAL NO.: 10/626,521 :

FILED: JULY 25, 2003 :

FOR: AQUEOUS DISPERSION FOR
CHEMICAL MECHANICAL POLISHING
AND PRODUCTION PROCESS OF
SEMICONDUCTOR DEVICE :

: EXAMINER: RACHUBA, MAURINA T.

: GROUP ART UNIT: 3723

"RESPONSE UNDER 37 CFR 1.116-
EXPEDITED PROCEDURE EXAMINING
GROUP 3723"

AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated August 6, 2007, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.